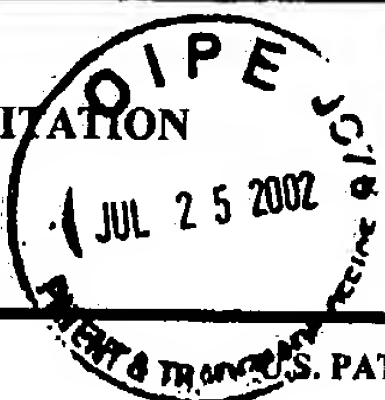


INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)



Docket Number (Optional)	Application Number
W 075	09/914,204
Applicant(s) John MACNEIL et al.	
Filing Date	Group Art Unit
February 20, 2002	2812

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
ET	A	6,028,015	02/22/2000	WANG et al.	438	789	—

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REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

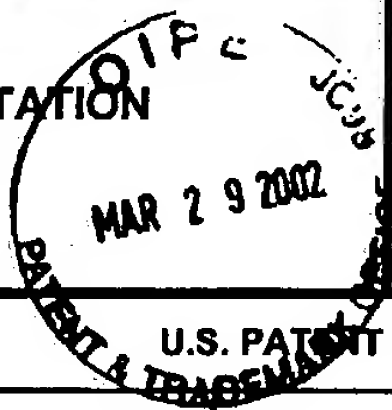
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INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)				ATTY DOCKET NO. WLJ.075		SERIAL NO. 09/914,204	
				John MacNeil FILING 08/23/2001			



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*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
ET	A	3,223,040	12/14/1965	DINKELKAMP	417	3	—
ET	B	4,793,524	12/27/1988	STARR	222	309	—
ET	C	5,095,938	03/17/1992	GARRISON	137	500	—
ET	D	5,098,741	03/24/1992	NOLET ET AL.	427	248.1	—
ET	E	5,195,655	03/23/1993	BUKHMANN	222	1	—
ET	F	5,273,851	12/28/1993	TAKEI ET AL.	430	67	—
ET	G	5,314,724	05/24/1994	TSUKUNE ET AL.	427	489	—
ET	H	5,356,034	10/18/1994	SCHLUMBERGER	222	61	—
ET	I	5,494,712	02/27/1996	HU ET AL.	427	489	—
ET	J	5,534,069	07/09/1996	KUWABARA ET AL.	118	719	—
ET	K	5,593,741	01/14/1997	IKEDA	427	579	—

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		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
ET	L	GB 2 280 169 A	01/25/1995	UNITED KINGDOM	—	—	✓	
ET	M	GB 2 220 869 A	01/24/1990	UNITED KINGDOM ^{corr. to}	4885,001	—	✓	
ET	N	GB 2 111 064 A	06/29/1983	UNITED KINGDOM ^{corr. to}	4839,379	—	✓	
ET	O	GB 2 108 133 A	05/11/1983	UNITED KINGDOM ^{corr. to}	4825,694	—	✓	
ET	P	EP 0 529 334 A2	03/03/1993	EPO ^{corr. to}	US 5,361,800	—	✓	

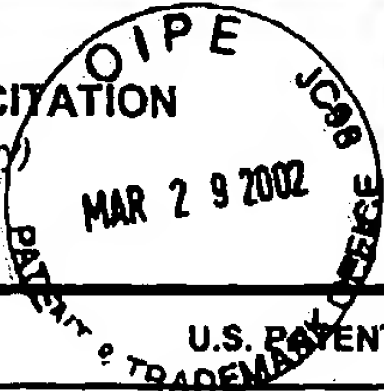
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ET	Q	Kamiya Kazuo, "Production of Silicon Dioxide Coating," Patent Abstracts of Japan, Publication No. 10310866, Publication Date 24-11-98
ET	R	A. Grill et al, "Low dielectric constant films prepared by plasma-enhanced chemical vapor deposition from tetramethylsilane," Journal of Applied Physics, Volume 85, Number 6, 15 March 1999, pages 3314-3318.

EXAMINER ETSOY	DATE CONSIDERED 12/2/03
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INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)				ATTY DOCKET NO. WLJ.075		SERIAL NO. 09/914,204	
				John MacNeil			
FILING 08/23/2001				GROUP UNKNOWN			



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*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
ET	S	5,876,503	03/02/1999	ROEDER ET AL.	118	773	RECEIVED -
ET	T	5,620,524	04/15/1997	FAN ET AL.	118	726	JUL 05 2002 -
ET	U	5,641,559	06/24/1997	NAMIKI	428	246	TC 1700 -
ET	V	5,730,804	03/24/1998	GOMI ET AL.	118	726	1 -
ET	W	5,786,039	07/28/1998	BROUQUET	427	568	RECEIVED -

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							YES	NO
ET	X	EP 0 254 205 A2	01/27/1998	EPO corr. to 4,762,730	—	—		✓
ET	Y	EP 0 726 599 A2	08/14/1996	EPO	—	—	✓	
ET	Z	EP 0 212 691	03/04/1987	EPO corr. to US 4,485,054	—	—	✓	
ET	AA	EP 0 826 791 A2	03/04/1998	EPO	—	—	✓	
ET	BB	WO 98/23787	06/05/1998	EPO	—	—	✓	

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INFORMATION DISCLOSURE CITATION
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Docket Number (Optional)
WLJ.075

Application Number
09/914,204

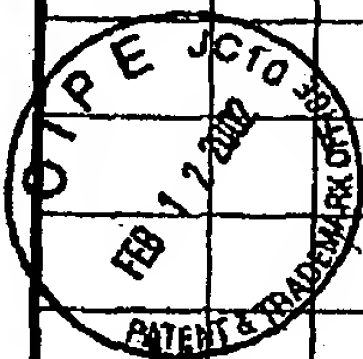
Applicant(s)
John MACNEIL

Filing Date
08/23/01

Group Art Unit
UNKNOWN

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EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
ET	A	4,894,254	01/16/90	NAKAYAMA et al.	427	539	—
ET	B	4,822,632	04/18/89	WILLIAMS et al.	427	536	—
ET	C	4,096,315	06/20/78	KUBACKI	428	412	—



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							YES	NO
ET	D	WO 98/08249	02/26/98	PCT	—	—	✓	
ET	E	WO 94/01885	01/20/94	PCT	—	—	✓	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

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INFORMATION DISCLOSURE CITATION
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Docket Number (Optional)

WLJ.075

Application Number

NEW

Applicant(s)

John MACNEIL et al.

09/914204

Filing Date

AUGUST 23, 2001

Group Art Unit

TO BE ASSIGNED

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*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
ET	A	5.270,267	12/14/93	OUELLET	438	597	—

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							YES	NO
ET	B	EP 0 761 841 A1	03/12/1997	EPO	—	—	✓	
ET	C	EP 0 519 079 A1	07/23/1992	EPO Corr. to US 5,314,724	—	—	✓	
ET	D	DE 196 54 737 A1	12/30/96	GERMANY Abs only	—	—		✓

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